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## (54) SKIN DRUG FOR EXTERNAL USE

## (57)Abstract:

PURPOSE: To obtain a skin drug for external use, containing kojic acids and ATP, ADP, AMP or succinic acids, having excellent cell activating action and effective in improving effects on skin roughening and wound curing promoting effects on traumas, cracks, chaps, etc.

CONSTITUTION: A skin drug for external use containing 0.0001-5wt.% kojic acid and/or a derivative thereof and 0.001-5wt.% one or two or more ingredients selected from adenosine triphosphate(ATP), adenosine diphosphate(ADP), adenosine monophosphate(AMP), succinic acid and derivatives thereof as active ingredients. Furthermore, an aqueous ingredient, powder, surfactant, humectant, coloring matter, antioxidant, etc., used in ordinary skin drugs for external use are suitably blended therewith and prepared according to a conventional method to afford the objective substance. The aforementioned drug can be applied as a skin drug for external use of medicinal, quasi-drug or cosmetic applications such as milky lotion, cream, toilet water, pack or detergent and further the form of dispersion, granule, ointment, etc.

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